

PATENT

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Patent Application of: Sun Jin YUN, et al.

Serial No.: New Application      Group Art Unit: Not Yet Assigned

Filed: February 13, 2004      Examiner: Not Yet Assigned

Title: SUBSTRATE WITH MICROSTRUCTURE FORMED THEREON AND  
MANUFACTURING METHOD THEREOF

**INFORMATION DISCLOSURE STATEMENT**

Honorable Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

February 13, 2004

Sir:

As a means of complying with the duty of disclosure under 37 CFR §1.56, and in accordance with 37 CFR §§1.97 and 1.98, Applicant(s), through the undersigned attorney, submits this Information Disclosure Statement. The patents, publications or other information submitted herewith are listed on the attached Form PTO-1449 and copies are attached.

In accordance with 37 CFR §1.97(b)(1) or (2), this Information Disclosure Statement is being filed either within three months of the filing date of the above-identified application, or within three months of the date of entry into the national stage of the above-identified application as set forth in 37 CFR §1.491. Accordingly, no fee is required.

Respectfully submitted,

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LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT

ATTY. DOCKET NO.: P69506US0 GROUP ART UNIT: Not Yet Assigned  
 SERIAL NO.: New Application FILING DATE: February 13, 2004  
 APPLICANT(S): Sun Jin YUN, et al. TODAY'S DATE: February 13, 2004

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**U.S. PATENT DOCUMENTS**

*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	INT'L CLASS	SUB- CLASS	FILING DATE (If Appropriate)	
_____	AA	<u>6,118,502</u>	<u>09/12/00</u>	<u>Yamazaki et al.</u>	<u>G02F</u>	<u>1/1343</u>	<u>04/20/98</u>
_____	AB	_____	_____	_____	_____	_____	_____
_____	AC	_____	_____	_____	_____	_____	_____

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**FOREIGN PATENT DOCUMENTS**

	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB- CLASS	TRANSLATION (YES) (NO)
_____	AD	_____	_____	_____	_____	_____
_____	AE	_____	_____	_____	_____	_____
_____	AF	_____	_____	_____	_____	_____

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**OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)**

\_\_\_\_\_ AG \_\_\_\_\_  
 \_\_\_\_\_

EXAMINER

DATE CONSIDERED

\* EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant(s).